L Number	Hits	Search Text	DB	Time stamp
2	15		USPAT;	2003/01/02
		117/\$4.ccls. and \$2CVD	US-PGPUB; EPO; JPO; DERWENT; IBM TDB	16:22
3	26	117/\$4.ccls. and \$2CVD	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/01/02 16:27
4	20	117/\$4.ccls. and \$2CVD	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/01/02 16:35
5		total adj pressure near4 control\$4 and 117/\$4.ccls. and "iii-v"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/02 16:36
-	112	thermal) near4 control\$4 same substrate and "iii-v"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/31 12:25
_		117/84-109.ccls. and (temperature or thermal) near4 control\$4 same substrate and "iii-v" same nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/31 12:30
-	19	117/84-109.ccls. and (temperature or thermal) near4 control\$4 and "iii-v" same nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/31 12:49
-		117/84-109.ccls. and (temperature or thermal) near4 source and "iii-v" same nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/31 12:54
-	6	117/84-109.ccls. and (temperature or thermal) same mix\$4 same reactant and "iii-v" same nitride	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/31 13:06
-	. 75	117/84-109.ccls. and (temperature or thermal) same mix\$4 same reactant	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2002/12/31 13:33
-		(117/84-109.ccls. and (temperature or thermal) same mix\$4 same reactant) and "iii-v"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/31 13:15
-		117/84-109.ccls. and (temperature or thermal) near2 outlet and "iii-v"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/12/31 13:48
_		117/84-109.ccls. and (temperature or thermal) near5 exhaust and "iii-v"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/02 10:03

-	1	"PCT/DE99/03863"		
-	19	"PCT/DE99/03863" heuken.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM TDB	2003/01/02 10:09 2003/01/02 16:13
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